

**I. IN THE CLAIMS:**

1. (Currently Amended) A composition for chemical mechanical planarization comprising an aqueous solution of ozone and abrasive particles-, wherein a concentration of ozone in said aqueous solution is less than that at which ozone interactions occur.

2. (Original) A composition as in claim 1 wherein said abrasive particles are selected from the group consisting of alumina, silica, ceria, spinel, zirconia and mixtures thereof.

3. (Original) A composition as in claim 1 further comprising at least one additive selected from the group consisting of carbonate, bicarbonate, oxalic acid, formic acid, acetic acid, glycol acids and mixtures thereof.

4. (Canceled)

5. (Currently Amended) A composition as in claim [[4]] 1 wherein said concentration of ozone is less than about 20 parts per million.

6. (Original) A composition as in claim 1 further comprising at least one ammonium salt.

7. (Original) A composition as in claim 6 wherein said at least one ammonium salt is ammonium carbonate.

8. (New) A composition as in claim 1 wherein said abrasive particles are selected from the group consisting of alumina, ceria, spinel, zirconia and mixtures thereof.

9. (New) A composition as in claim 1 further comprising at least one additive selected from the group consisting of bicarbonate, oxalic acid, formic acid, glycol acids and mixtures thereof.